

ABSTRACT

There is explained a fabrication method of a liquid crystal display panel capable of simplifying a substrate structure and a fabrication process.

The fabrication method comprises the steps of: forming a thin film transistor formed at every region arranged by the intersection structure of a gate line and a data line formed on a substrate, a pixel electrode, and a substrate including a plurality of thin film transistor array substrate having a gate pad part including a gate pad connected to the gate line and a data pad part including a data pad connected to the data line; arranging a cutting-off plate on a rest region of the substrate except for the pad part; and exposing the gate pad of the pad part and the data pad protection electrode by a etching process using the cutting-off plate.